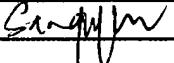


ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention	METHODS FOR HIGH-PRECISION GAP AND ORIENTATION SENSING BETWEEN A TRANSPARENT TEMPLATE AND SUBSTRATE FOR IMPRINT LITHOGRAPHY						
Application Number :	09/920341						
Confirmation Number:	4146						
First Named Applicant:	Byung Choi						
Attorney Docket Number:	PA17-07V06						
Art Unit:	2877						
Examiner:	Sang H. Nguyen						
Search string:	(5414514 or 5808742 or 6522411).pn						
US Patent Documents							
Note: Applicant is not required to submit a paper copy of cited US Patent Documents							
init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
SN	1	5414514	1995-05-09	Smith et al.			
SN	2	5808742	1998-09-15	Everett et al.			
SN	3	6522411	2003-02-18	Moon et al.	B1		
Signature							
Examiner Name				Date			
				04/28/05			

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

METHODS FOR HIGH-PRECISION GAP AND ORIENTATION
SENSING BETWEEN A TRANSPARENT TEMPLATE AND
SUBSTRATE FOR IMPRINT LITHOGRAPHY

Application Number : 09/920341
Confirmation Number: 4146
First Named Applicant: Byung Choi
Attorney Docket Number: PA17-07V06
Art Unit: 2877
Examiner: Sang H. Nguyen
Search string: (6190929).pn



US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
SN	1	6190929	2001-02-20	Wang et al.	B1	—	—

Signature

Examiner Name	Date
Sang H. Nguyen	07/28/05